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Experimental inspection of a computationally-designed NiCrMnSi Heusler alloy with high Curie temperature

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Nowadays advanced magnetic tunnel junction applications demand very high tunnel magnetoresistance at 14 room temperature, thus it is quite important to explore high Curie temperature T_c half-metallic Heusler 15 alloys. In this article first-principles calculation unveiled that NiCrMnSi has T_c of 1200 K comparable to 16 that of the traditional Co_2MnSi Heusler alloys, even though it does not contain Co element. In addition, 17 we examined whether NiCrMnSi Heulser phase films can be obtained by a magnetron sputtering on MgO 18 substrates. The results of the structural analysis and first-principles calculations indicated that NiCrMnSi 19 Heusler phase is metastable. A possible route to obtain metastable NiCrMnSi Heusler alloy is to utilize 20 appropriate templates. 21

22 1. Introduction

Magnetic tunnel junctions (MTJs) are currently being widely used for various com-23 mercial applications, such as storage, sensor, and memory. More recently, advanced 24 computing technologies are emergent and demand MTJs exhibiting much higher tun-25 nel magnetoresistance (TMR) ratio at room temperature.¹⁻³⁾ Large TMR ratios can 26 be obtained in MTJs with a use of electrodes of half-metallic ferromagnets which are 27 magnetic metals having a band gap at the Fermi level for their minority spin state.⁴⁾ A 28 Co₂-based Heusler alloy is one of the candidates of half-metals and attracted much at-29 tention to date.⁵⁾ Among several kinds of Co_2 -based Heusler alloys, a promising one for 30

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¹ MTJs is Co₂MnSi.⁶⁾ Indeed, MTJs with electrodes of Co₂MnSi or of the ones with Mn ² partially substituted by Fe showed the record of the TMR ratio of about 2600% at low ³ temperature.⁷⁾ However, this TMR ratio is significantly reduced at room temperature.⁷⁾ ⁴ The reduction of the TMR ratio with elevating temperature is due to thermal fluctua-⁵ tion of a magnetic moment,^{8–10)} hence it can be suppressed with use of half-metals with ⁶ higher Curie temperatures T_c .

A numerous elemental combinations in Heusler alloys enabled us to find new compositions showing unconventional electronic structures, such as a spin gapless semiconductor.¹¹⁾ Furthermore, computation-based exploration are much progressed.^{12–15)} However, there are yet no computational reports focusing on half-metallic Heusler alloys with high T_c beyond those of Co₂MnSi and the derivatives.

As a first step of computational/experimental explorations for high T_c half-metallic 12 Heusler alloys, we theoretically and experimentally studied NiCrMnSi equiatomic qua-13 ternary alloys in this article. The *ab-initio* calculations unveiled, for the first time, that 14 the NiCrMnSi Heusler alloy has attractive properties; such as a small net magnetic 15 moment due to the ferrimagnetic spin structure, high T_c , and large spin polarization, 16 even though elemental compositions are different from Co_2 -based Heusler alloys. We 17 also examined whether film growth of NiCrMnSi is possible using a magnetron sput-18 tering technique. The experiments indicated that NiCrMnSi films are decomposed into 19 other alloys/compounds without crystallizing into Heusler phase. This phase separation 20 observed in the experiments is explained with the formation energies for NiCrMnSi and 21 the others, and indicating that NiCrMnSi Heusler phase is rather metastable. A possible 22 route to obtain the Heusler phase film of NiCrMnSi is discussed. 23

24 2. First-principles calculations

Ab-initio calculation of NiCrMnSi has been performed using Vienna Ab Initio Simulation Package,¹⁶⁾ in combination with the projector augmented wave method.¹⁷⁾ For the exchange correlation potential, we used the generalized gradient approximation (GGA).¹⁸⁾ The energy cutoff of 500 eV has been set for the plane waves, and the final energies have been calculated with a k-mesh of $8 \times 8 \times 8$ for the cubic case and a comparable number of k-points used for the tetragonal case. The energy and the force tolerance were 10 μ eV and 10 meV/Å, respectively.

Magnetic interactions and the detail insight of magnetism have been probed using Green's function based spin-polarized relativistic Korringa-Kohn-Rostoker method

XX'YZ	structure	$\Delta E_{\rm XX'YZ}$ (eV/f.u.)	a (Å)	c/a
NiCrMnSi	cubic	-1.033	5.710	
	tetragonal	-1.151	5.285	1.270
MnNiCrSi	cubic	-0.974	5.681	
	tetragonal	-1.118	5.213	1.254
MnCrNiSi	cubic	-0.402	5.658	
	tetragonal	-0.794	5.046	1.457

Table I. Calculated formation energies $\Delta E_{XX'YZ}$ and lattice constant *a* for cubic and tetragonal Ni-Cr-Mn-Si Heusler alloys with different types. c/a is the axial ratio of the tetragonal unit cell.

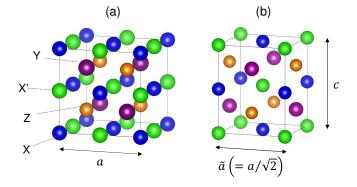


Fig. 1. Illustration of a crystal structure of Y ordered equiatomic Heusler alloy XX'YZ with (a) cubic (a = c) or (b) tetragonal $(a \neq c)$ lattice. Cubic XX'YZ Heusler structure has a space group of $F\bar{4}3m$ (no. 216) and tetragonal lattice has a space group of $I\bar{4}m2$ (no. 119).

(SPR-KKR) as implemented in the programme package.¹⁹⁾ We calculate the Heisenberg 1 exchange coupling constant within a real space approach as proposed by Liechenstein et 2 $al.^{20}$ Furthermore, T_c has been calculated in terms of the Heisenberg exchange coupling 3 constant, within mean field approximation. For the self-consistent-field calculations we 4 use the full-potential method and GGA for the exchange correlation potential. We use 5 824 irreducible k-points for the Brillouin zone integration and an angular momentum 6 expansion up to 3 has been used for each atom. 90 energy points on the complex energy 7 path were used. 8

We evaluated the formation energy for the three types of ordered structure of NiCrMnSi with cubic or tetragonal structures, as shown in Fig. 1. Here the formation energy $\Delta E_{\rm XX'YZ}$ is defined as,

$$\Delta E_{XX'YZ} = E_{XX'YZ} - [E_X + E_{X'} + E_Y + E_Z], \qquad (1)$$

¹² where $E_{XX'YZ}$ denotes the total energy of the Heusler alloy XX'YZ, and E_X , $E_{X'}$, E_Y

Table II. Physical properties of tetragonal NiCrMnSi predicted from the first principles; the Curie temperature T_c , the spin polarization P, the basal plane lattice constant a, the axial ratio c/a, and the total magnetic moment m_{tot} . The values for Co₂MnSi similarly calculated from the first principles are also shown for comparison. Values in the parentheses correspond to the partial magnetic moments of Ni, Cr, and Mn atom for NiCrMnSi and those of Co and Mn atom for Co₂MnSi, respectively.

Material	T_c (K)	P(%)	a (nm)	c/a	$m_{ m tot}~(\mu_B/{ m f.u.})$
NiCrMnSi	1200	88	0.528	1.27	$0.95\ (0.13,\ -1.79,\ 2.61)$
$\mathrm{Co}_{2}\mathrm{MnSi}$	1204	100	0.563	1.00	$5.00 \ (1.02, \ 2.99)$

and $E_{\rm Z}$ are those of elemental solids, X, X', Y and Z, respectively. Then we found 1 the tetragonal type of NiCrMnSi is the most stable in terms of the formation energy, 2 as shown in Table I. The predicted physical properties are summarized in Table II. 3 We also calculated the values for Co_2MnSi from the first principles and those are also 4 shown in the Table II for comparison. The Curie temperature of NiCrMnSi is as high 5 as that of Co₂MnSi, which stems from the large antiferromagnetic exchange interaction 6 between magnetic moments for Cr and Mn. Note that the mean-field approximation 7 usually tends to overestimate the Curie temperature since it neglects the thermal fluc-8 tuation of magnetic moments. Indeed, the Curie temperature experimentally observed 9 for Co₂MnSi was 990 K.²¹⁾ Total magnetic moment is close to 1 μ_B and the spin polar-10 ization is close to unity, because the Fermi level is located near the top of the valence 11 band edge for the minority spin state, as shown in Fig. 2(a). Importantly, the Δ_1 band 12 dispersion along the [001] axis is located across the Fermi level for the majority spin 13 state and no Δ_1 bands are located at the Fermi level for the minority spin state, as 14 shown in Figs. 2(b) and 2(c), respectively. This means that the Δ_1 band which de-15 termines the TMR ratio in MgO-based MTJs is fully spin polarized, hence the large 16 TMR ratio is expected, as theoretically predicted and experimentally observed in bcc 17 Fe(-Co)/MgO MTJs.^{22–26)} 18

19 3. Experiments

20 3.1 Experimental procedures

All samples were prepared by a magnetron sputtering system with a base pressure of 2×10^{-7} Pa, as previously used in different Heusler alloy films.^{27–30)} The single crystal MgO(001) substrates were cleaned by ultrasonic cleaning in an acetone and an ethanol prior to being introducing into the load-lock chamber. Sample stacking structure was

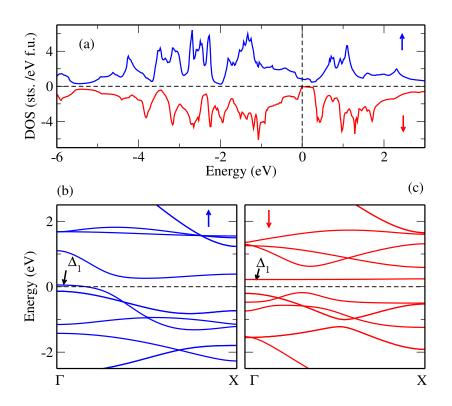


Fig. 2. Electronic structure calculated from the first principles for a tetragonal NiCrMnSi. (a) The density-of-states, and the band dispersion along the [001] axis for (b) majority and (c) minority spin states.

MgO(001) substrate /NiCrMnSi(100 nm)/Ta(3 nm). The substrates were thermally 1 flushed at 700°C in the chamber to remove residual organic substances and water. 2 NiCrMnSi layers were deposited by a co-sputtering technique using NiCr and MnSi alloy 3 targets. Powers were 100 W, 30 W, 26 W and 60 W in the Cr, NiCr, MnSi and Ta targets, 4 respectively. The composition of Ni : Cr : Mn : Si in the films was evaluated as 25.9 : 5 29.5 : 23.0 : 21.6 (at%) by an inductively coupled plasma mass spectrometry (ICP-6 MS). The 100-nm-thick NiCrMnSi layers were deposited at a substrate temperature 7 T_s of 500–800°C. Finally, Ta capping layers were deposited at room temperature. The 8 crystalline structure of the samples was measured by an out-of-plane X-ray diffraction 9 (XRD) with Cu K_{α} radiation (wavelength of 0.15418 nm) and a transmission electron 10 microscope (TEM). Magnetic property was measured using a polar magneto-optical 11 Kerr effect (p-MOKE) with a maximum magnetic field of 2 T and a laser wavelength 12 of approximately 400 nm. Magnetization measurements were also carried out using a 13 vibrating sample magnetometer (VSM) with a maximum in-plane magnetic field of 2 14

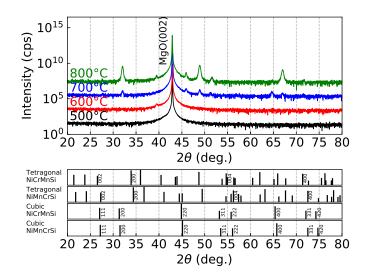


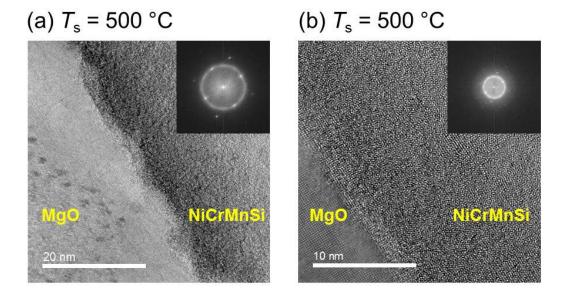
Fig. 3. Out of plane XRD patterns of NiCrMnSi films with different deposition temperatures. Theoretical diffraction patterns for the NiCrMnSi and NiMnCrSi Heusler phases with cubic and tetragonal structures are shown at the bottom.

1 T.

2 3.2 Experimental results

The out-of-plane XRD patterns for the NiCrMnSi films on MgO substrates with dif-3 ferent deposition temperatures are shown in Fig. 3. The powder diffraction patterns 4 for the NiCrMnSi Heusler phase with cubic and tetragonal structures are theoretically 5 simulated and are also plotted at the bottom for comparison. The diffraction peaks 6 were observed for the samples with $T_s \geq 700^{\circ}$ C and the peak intensity increased with 7 increasing the annealing temperature. However, the peak positions were not consistent 8 with those from the cubic or tetragonal phase. Therefore, the other phases might be 9 formed in these samples. However, there are many candidates consisting each element 10 corresponding to these peaks and it is difficult to identify the formed phases from these 11 XRD patterns. 12

To consider the phase formed in these samples, TEM observation was performed. Figures 4(a) and 4(b) show the TEM images for NiCrMnSi films deposited on MgO substrates at 500°C with low and high magnification, respectively. Figures 4(c) and 4(d) similarly show those for the films deposited at 700°C with low and high magnification, respectively. The corresponding diffraction patterns are included as insets in these figures. In the case for the sample deposited at 500°C, some short-range crystallization phases were observed and the ring pattern for the diffraction images indicated



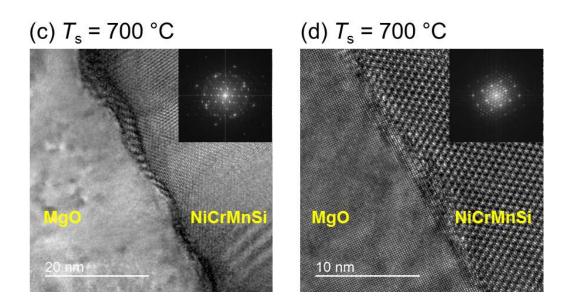


Fig. 4. TEM images of NiCrMnSi deposited at 500°C and 700°C. (a) Low and (b) high magnification images for NiCrMnSi deposited at 500°C. (c) Low and (d) high magnification images for NiCrMnSi deposited at 700°C. Insets are the corresponding selected beam electron diffraction pattern.

the formation of polycrystalline. Because of the short-range crystallization, XRD measurements showed no diffraction peak in Fig. 3. On the other hand, in the case for the
sample deposited at 700°C, the grain boundaries are observed clearly for the images
with low magnification. It suggested the grain sizes are larger than those for the sample
deposited at 500°C. Furthermore, the diffraction spots were observed and suggested

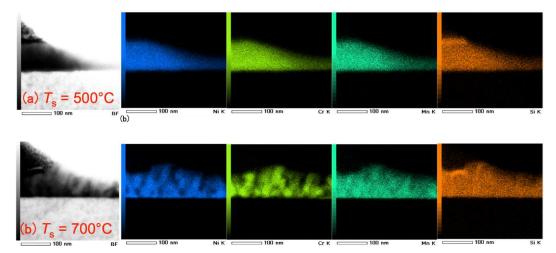


Fig. 5. Element mapping images by TEM-EDX for NiCrMnSi samples deposited at (a) 500°C and (b) 700°C. Left images are TEM images. Blue, yellow green, and orange data points corresponding to the Ni, Cr, Mn and Si elements, respectively.

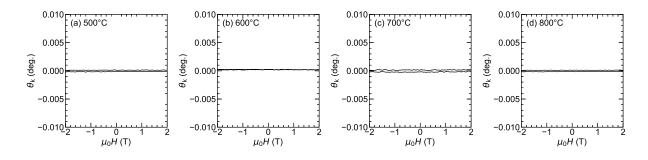


Fig. 6. p-MOKE results for the NiCrMnSi deposited at (a) 500°C, (b) 600°C, (c) 700°C, and (d) 800°C.

that multiple crystalline phases were formed as seen as their overlapped patterns. Observation agrees with the fact that many diffraction peaks were observed in the XRD
measurements for the sample deposited at 700°C in Fig. 3.

For further analysis, the elemental mapping was performed by energy dispersive X-4 ray spectrometry (EDX) in the TEM apparatus. Figures 5(a) and 5(b) show the cross-5 sectional TEM images and elemental mapping images for NiCrMnSi films deposited 6 at 500°C and 700°C, respectively. Left figures are cross-sectional TEM images and the 7 other four figures are elemental mapping images. Blue, yellow-green, green, and orange 8 correspond to the detected Ni, Cr, Mn, and Si elements, respectively. For the sample 9 deposited at 500°C, all four elements were homogeneously distributed in a whole region. 10 However, non-uniform distributions for Ni and Cr atoms were observed and these are 11 complementary for the sample deposited at 700°C. It suggests that the Ni-rich phase 12

¹ and the Cr-rich phase were spatially separated in this sample.

² The magnetic properties of NiCrMnSi films were measured by using the p-MOKE.

³ Figure 6 shows the out-of-plane MOKE curves for the NiCrMnSi films with different

4 deposition temperatures. No hysteresis loop was observed for all the samples even at

⁵ the deposition temperature of 800°C. Some samples were also measured using VSM,

⁶ however, no hysteresis loop was observed. These results suggested that all samples in

7 this study showed paramagnetism or antiferromagnetism at room temperature.

8 4. Discussion

To investigate which phases were formed, the out-of-plane XRD pattern with the wide 9 range from 10° to 90° for the sample deposited at 800° C is shown in Fig. 7(a). From the 10 XRD analysis and TEM observation, (001)-orientated Mn₆Ni₁₆Si₇ and Mn₃Si may be 11 formed as dominants phases in the samples. Figures 7(b) and 7(c) show the crystalline 12 lattices of Mn₆Ni₁₆Si₇ and Mn₃Si, respectively. Mn₆Ni₁₆Si₇ and Mn₃Si are antiferro-13 magnets with the Neel temperatures of $\simeq 200 \text{ K}^{31}$ and 23 K,³²⁾ respectively. Therefore, 14 this analysis is consistent with the magnetic measurements which showed no hysteresis 15 loop in Fig. 6. In addition to the above mentioned phases, there exist minor phases. 16 For example, some peaks as appeared in Fig. 3 and Fig. 7(a) cannot be attributed to 17 Mn₆Ni₁₆Si₇, and Mn₃Si. Those unknown phases may be Cr-rich alloys or compounds 18 and minor residues. 19

The phase stability can be discussed by the difference δE in the formation energy of NiCrMnSi and alloys/compounds decomposed. When we assume that the abovementioned unknown phases are Cr₃Si and Si, δE is evaluated as,

$$\delta E = \Delta E_{\rm NiCrMnSi} - \left[\frac{1}{16}\Delta E_{\rm Mn_6Ni_{16}Si_7} + \frac{5}{24}\Delta E_{\rm Mn_3Si} + \frac{1}{3}\Delta E_{\rm Cr_3Si} + \frac{1}{48}\Delta E_{\rm Si}\right].$$

Here, $\Delta E_{\rm Mn6Ni16Si7}$, $\Delta E_{\rm Mn3Si}$, $\Delta E_{\rm Cr3Si}$, and $\Delta E_{\rm Si}$ are the formation energies of bulk Mn6Ni16Si7, Mn3Si, Cr3Si, and Si, respectively which are found to be -12.686 eV/f.u., -1.334 eV/f.u., -1.436 eV/f.u., and 0 eV/f.u. After substituting these values in the above equation, we obtain $\delta E = 0.396 \text{ eV/f.u}$. The positive value of δE means that the Heusler phase of NiCrMnSi is not stable at ground state and tends to be decomposed into the others in the bulk form. Thus this analysis reasonably accounts the experimental observations.

³⁰ Above discussion implies that the Heusler phase of NiCrMnSi is rather metastable.

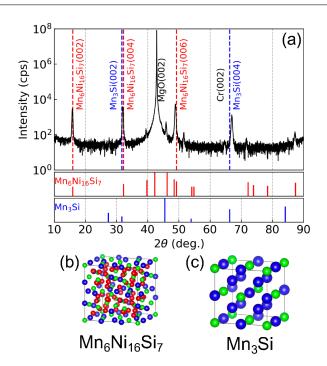


Fig. 7. (a) Wide range out of plane XRD pattern of NiCrMnSi deposited at 800°C. Theoretical diffraction patterns for $Mn_6Ni_{16}Si_7$ and Mn_3Si are shown at the bottom. Cartoons of the crystal lattice of (b) $Mn_6Ni_{16}Si_7$ and (c) Mn_3Si .

In general, metastable phases of alloy films can be obtained when those are grown on
an appropriate template with optimized growth conditions such as film thickness and
growth temperatures. In particular, relatively low temperature growth on a specific alloy
template would be effective, as well known in tetragonal Mn-based Heusler alloys and
those derivatives, for example.³³⁻⁴⁰⁾ Thus, it would be crucial to find good templates
for obtaining the Heusler phase of NiCrMnSi, which is left as a future subject.

7 5. Summary

We theoretically and experimentally studied on NiCrMnSi equiatomic Heusler alloys. 8 The first principles calculation predicted that the tetragonal NiCrMnSi was energeti-9 cally favorable compared with the cubic phase and possessed the high Curie temperature 10 and the fully spin-polarized electronic band along [001] directions. NiCrMnSi equiatomic 11 alloy films were fabricated by magnetron sputtering. The XRD measurements indicated 12 that several phases were formed for the samples deposited at high deposition tempera-13 tures. The TEM observation showed that the Ni-rich and Cr-rich phases were spatially 14 separated in those films. The p-MOKE and VSM measurements showed no magnetic 15 hysteresis loop, which suggested that all samples have paramagnetism or antiferromag-16

netism at room temperature. This phase separation was also theoretically explained
in terms of the formation energies of NiCrMnSi and the other decomposed alloys and
compounds. A possible route to obtain the NiCrMnSi single phase Heusler alloys as the
metastable phase is to utilize more appropriate template to promote the crystallization
of NiCrMnSi Heusler alloys at relatively lower temperature.

6 acknowledgement

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